

**AMENDMENTS TO THE SPECIFICATION:**

Please replace Paragraph [0038] with the following amended paragraph:

FIG. 5 is a processing flow chart representing an exemplary general liquid crystal display device according to an embodiment of the present invention. Specifically, a process for fabricating an in-plane switching mode liquid crystal display panel is shown in FIG. 5. First, a thin film transistor substrate and a color filter substrate may be provided (S11, S12), wherein a plurality of thin film transistors may have been formed on the thin film transistor substrate, and a color filter may have been formed on the color filter substrate. In this regard, an exemplary process for fabricating the thin film transistor substrate is shown in FIGs. 2A to 2E.

Please replace Paragraph [0050] with the following amended paragraph:

FIG. 6 is a plan view showing an exemplary layout of a test step following the liquid crystal injection and the scribe/break process according to an embodiment of the present invention. As shown in FIG. 6, a cleaning unit 101 and a light [[lighting]] test unit 113 are arranged serially. The cleaning unit may clean impurities generated at the time of the grinding process, and the light ~~lighting~~ test unit is used to test a lighting condition of the liquid crystal display. Moreover, a robot 107 is arranged at a desired position for transferring the liquid crystal display panel.

Please replace Paragraph [0051] with the following amended paragraph:

The testing arrangement depicted in FIG. 6 may further include a buffer 103 for storing the cleaned liquid crystal display panel before the lighting test, a supply table 115 for supplying the panel to the light ~~lighting~~ test unit 113, an input table 110 installed between the buffer 103 and the supply table 115, and an output table 111 for transferring the tested panel to a next process and a movable table 117.